

REPETITIVE AVALANCHE AND dv/dt RATED HEXFET® TRANSISTOR

IRHN9130 P-CHANNEL RAD HARD

-100 Volt, 0.30 Ω , RAD HARD HEXFET

International Rectifier's P-channel RAD HARD technology HEXFETs demonstrate excellent threshold voltage stability and breakdown voltage stability at total radiation doses as high as 10^5 Rads (Si). Under **identical** pre- and post-radiation test conditions, International Rectifier's P-channel RAD HARD HEXFETs retain **identical** electrical specifications up to 1×10^5 Rads (Si) total dose. No compensation in gate drive circuitry is required. These devices are also capable of surviving transient ionization pulses as high as 1×10^{12} Rads (Si)/Sec, and return to normal operation within a few microseconds. Single Event Effect, (SEE), testing of International Rectifier's P-channel RAD HARD HEXFETs has demonstrated virtual immunity to SEE failure. Since the P-channel RAD HARD process utilizes International Rectifier's patented HEXFET technology, the user can expect the highest quality and reliability in the industry.

P-channel RAD HARD HEXFET transistors also feature all of the well-established advantages of MOSFETs, such as voltage control, very fast switching, ease of paralleling and temperature stability of the electrical parameters.

They are well-suited for applications such as switching power supplies, motor controls, inverters, choppers, audio amplifiers and high-energy pulse circuits in space and weapons environments.

Product Summary

Part Number	BV _{DSS}	R _{DS(on)}	I _D
IRHN9130	-100V	0.30 Ω	-11A

Features:

- Radiation Hardened up to 1×10^5 Rads (Si)
- Single Event Burnout (SEB) Hardened
- Single Event Gate Rupture (SEGR) Hardened
- Gamma Dot (Flash X-Ray) Hardened
- Neutron Tolerant
- Identical Pre- and Post-Electrical Test Conditions
- Repetitive Avalanche Rating
- Dynamic dv/dt Rating
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed
- Surface Mount
- Lightweight

Absolute Maximum Ratings

Pre-Radiation

	Parameter	IRHN9130	Units
I _D @ V _{GS} = -12V, T _C = 25°C	Continuous Drain Current	-11	A
I _D @ V _{GS} = -12V, T _C = 100°C	Continuous Drain Current	-7.0	
I _{DM}	Pulsed Drain Current ^①	-44	
P _D @ T _C = 25°C	Max. Power Dissipation	75	W
	Linear Derating Factor	0.60	W/K ^②
V _{GS}	Gate-to-Source Voltage	±20	V
E _{AS}	Single Pulse Avalanche Energy ^③	500	mJ
I _{AR}	Avalanche Current ^④	-11	A
E _{AR}	Repetitive Avalanche Energy ^⑤	7.5	mJ
dv/dt	Peak Diode Recovery dv/dt ^⑥	-5.5	V/ns
T _J	Operating Junction	-55 to 150	°C
T _{STG}	Storage Temperature Range		
	Package Mount Surface Temperature	300 (for 5 seconds)	
	Weight	2.6 (typical)	g


IRHN9130 Device

Pre-Radiation

Electrical Characteristics @ $T_j = 25^\circ\text{C}$ (Unless Otherwise Specified)

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
BV_{DSS}	Drain-to-Source Breakdown Voltage	-100	—	—	V	$V_{GS} = 0V, I_D = -1.0\text{ mA}$
$\Delta BV_{DSS}/\Delta T_j$	Temperature Coefficient of Breakdown Voltage	—	-0.087	—	$V/^\circ\text{C}$	Reference to 25°C , $I_D = -1.0\text{ mA}$
$R_{DS(on)}$	Static Drain-to-Source	—	—	0.30	Ω	$V_{GS} = -12V, I_D = -7.0A$
	On-State Resistance	—	—	0.35		$V_{GS} = -12V, I_D = -11A$
$V_{GS(th)}$	Gate Threshold Voltage	-2.0	—	-4.0	V	$V_{DS} = V_{GS}, I_D = -1.0\text{ mA}$
g_{fs}	Forward Transconductance	2.5	—	—	S (Ω)	$V_{DS} > -15V, I_{DS} = -7.0A$
I_{DSS}	Zero Gate Voltage Drain Current	—	—	-25	μA	$V_{DS} = 0.8 \times \text{Max Rating}, V_{GS} = 0V$
		—	—	-250		$V_{DS} = 0.8 \times \text{Max Rating}$ $V_{GS} = 0V, T_j = 125^\circ\text{C}$
I_{GSS}	Gate-to-Source Leakage Forward	—	—	-100	nA	$V_{GS} = -20V$
I_{GSS}	Gate-to-Source Leakage Reverse	—	—	100		$V_{GS} = +20V$
Q_g	Total Gate Charge	—	—	45	nC	$V_{GS} = -12V, I_D = -11A$ $V_{DS} = \text{Max. Rating} \times 0.5$
Q_{gs}	Gate-to-Source Charge	—	—	10		
Q_{gd}	Gate-to-Drain ("Miller") Charge	—	—	25		
$t_{d(on)}$	Turn-On Delay Time	—	—	30	ns	$V_{DD} = -50V, I_D = -11A,$ $R_G = 7.5\Omega$
t_r	Rise Time	—	—	70		
$t_{d(off)}$	Turn-Off Delay Time	—	—	70		
t_f	Fall Time	—	—	70		
L_D	Internal Drain Inductance	—	TBD	—	nH	Measured from the drain lead, 6mm (0.25 in.) from package to center of die.
L_S	Internal Source Inductance	—	TBD	—		Measured from the source lead, 6mm (0.25 in.) from package to source bonding pad.
C_{iss}	Input Capacitance	—	1100	—	pF	$V_{GS} = 0V, V_{DS} = -25V$ $f = 1.0\text{ MHz}$
C_{oss}	Output Capacitance	—	310	—		
C_{rss}	Reverse Transfer Capacitance	—	55	—		

Source-Drain Diode Ratings and Characteristics

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
I _S	Continuous Source Current (Body Diode)	—	—	-11	A	Modified MOSFET symbol showing the integral reverse p-n junction rectifier. 
I _{SM}	Pulse Source Current (Body Diode) ①	—	—	-44		
V _{SD}	Diode Forward Voltage	—	—	-3.0	V	T _j = 25°C, I _S = -11A, V _{GS} = 0V ↴
t _{rr}	Reverse Recovery Time	—	—	250	ns	T _j = 25°C, I _F = -11A, di/dt ≤ -100A/μs V _{DD} ≤ -50V ↴
Q _{RR}	Reverse Recovery Charge	—	—	2.6	μC	
t _{on}	Forward Turn-On Time	Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by L _S + L _D .				

Thermal Resistance

	Parameter	Min.	Typ.	Max.	Units	Test Conditions
R_{thJC}	Junction-to-Case	—	—	1.67	K/W	Soldered to a copper clad PC board
$R_{thJ-PCB}$	Junction-to-PC Board	—	TBD	—		

IRHN9130 Device

Radiation Characteristics

Radiation Performance of P-Channel Rad Hard HEXFETs

International Rectifier Radiation Hardened HEXFETs are tested to verify their hardness capability. The hardness assurance program at International Rectifier uses two radiation environments.

Every manufacturing lot is tested in a low dose rate (total dose) environment per MIL-STD-750, test method 1019. International Rectifier has imposed a standard gate voltage of -12 volts per note 6 and a V_{DS} bias condition equal to 80% of the device rated voltage per note 7. Pre- and post-radiation limits of the devices irradiated to 1×10^5 Rads (Si) are identical and are presented in Table 1. The values in Table 1 will be met for either of the two low dose rate test circuits that are used.

Both pre- and post-radiation performance are tested and specified using the same drive circuitry and test conditions in order to provide a direct comparison. It should be noted that at a radiation level of 1×10^5 Rads (Si), no change in limits are specified in DC parameters.

High dose rate testing may be done on a special request basis, using a dose rate up to 1×10^{12} Rads (Si)/Sec.

International Rectifier radiation hardened P-Channel HEXFETs are considered to be neutron-tolerant, as stated in MIL-PRF-19500 Group D. International Rectifier P-Channel radiation hardened HEXFETs have been characterized in heavy ion Single Event Effects (SEE) environment and results are shown in Table 3.

Table 1. Low Dose Rate

Table 1. Low Dose Rate		IRHN9130			
Parameter		100K Rads (Si)		Units	Test Conditions
		min.	max.		
BV _{DSS}	Drain-to-Source Breakdown Voltage	-100	—	V	V _{GS} = 0V, I _D = -1.0 mA
V _{GS(th)}	Gate Threshold Voltage	-2.0	-4.0		V _{GS} = V _{DS} , I _D = -1.0 mA
I _{GSS}	Gate-to-Source Leakage Forward	—	-100	nA	V _{GS} = -20V
I _{GSS}	Gate-to-Source Leakage Reverse	—	100		V _{GS} = +20V
I _{DSS}	Zero Gate Voltage Drain Current	—	-25	μA	V _{DS} = 0.8 x Max Rating, V _{GS} = 0V
R _{DS(on)1}	Static Drain-to-Source On-State Resistance One	—	0.30	Ω	V _{GS} = -12V, I _D = -7A
V _{SD}	Diode Forward Voltage	—	-3.0	V	T _C = 25°C, I _S = -11 V _{GS} = 0V

Table 2. High Dose Rate

Parameter		10 ¹¹ Rads (Si)/sec			10 ¹² Rads (Si)/sec			Units	Test Conditions
		Min.	Typ.	Max.	Min.	Typ.	Max.		
V_{DSS}	Drain-to-Source Voltage	—	—	-80	—	—	-80	V	Applied drain-to-source voltage during gamma-dot
I_{PP}		—	-60	—	—	-60	—	A	Peak radiation induced photo-current
di/dt		—	—	-800	—	—	-160	A/ μ sec	Rate of rise of photo-current
L_1		0.1	—	—	0.5	—	—	μH	Circuit inductance required to limit di/dt

Table 3. Single Event Effects

Parameter	Typ.	Units	Ion	LET (Si) (MeV/mg/cm ²)	Fluence (ions/cm ²)	Range (μm)	V_{DS} Bias (V)	V_{GS} Bias (V)
BV_{DSS}	-100	V	Ni	28	1×10^5	~41	-100	+5

IRHN9130 Device

Radiation Characteristics

⌚ Repetitive Rating; Pulse width limited by maximum junction temperature.
Refer to current HEXFET reliability report.

⌚ @ $V_{DD} = -25V$, Starting $T_J = 25^\circ C$,
 $E_{AS} = [0.5 * L * (I_L^2) * [BV_{DSS}/(BV_{DSS} - V_{DD})]]$
Peak $I_L = -11A$, $V_{GS} = -12V$, $25 \leq R_G \leq 200\Omega$

⌚ $I_{SD} \leq -11A$, $di/dt \leq -140A/\mu s$,
 $V_{DD} \leq BV_{DSS}$, $T_J \leq 150^\circ C$
Suggested $R_G = 7.5\Omega$

⌚ Pulse width $\leq 300 \mu s$; Duty Cycle $\leq 2\%$

⌚ $K/W = ^\circ C/W$
 $W/K = W/^\circ C$

⌚ **Total Dose Irradiation with V_{GS} Bias.**
-12 volt V_{GS} applied and $V_{DS} = 0$ during

irradiation per MIL-STD-750, method 1019.

⌚ **Total Dose Irradiation with V_{DS} Bias.**

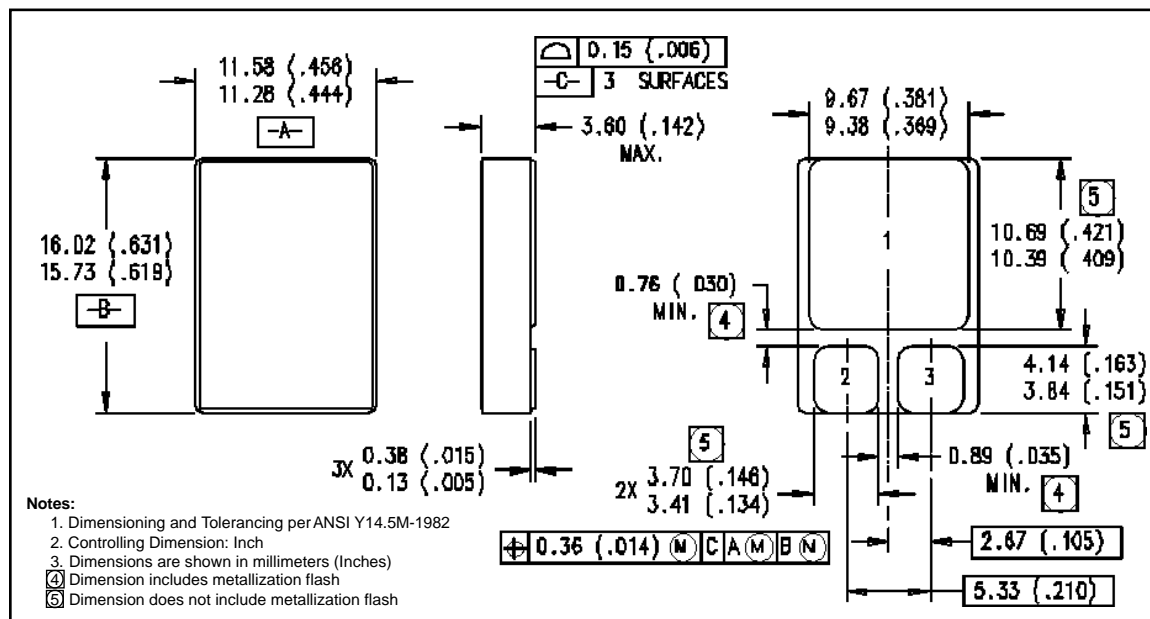
$V_{DS} = 0.8$ rated BV_{DSS} (pre-radiation)
applied and $V_{GS} = 0$ during irradiation per
MIL-STD-750, method 1019.

⌚ This test is performed using a flash x-ray
source operated in the e-beam mode
(energy ~2.5 MeV), 30 nsec pulse.

⌚ Study sponsored by NASA. Evaluation performed at
Brookhaven National Labs.

⌚ All Pre-Radiation and Post-Radiation test
conditions are **identical** to facilitate direct
comparison for circuit applications.

Case Outline and Dimensions — SMD-1

**CAUTION****BERYLLIA WARNING PER MIL-PRF-19500**

Packages containing beryllia shall not be ground, sandblasted, machined, or have other operations performed on them which will produce beryllia or beryllium dust. Furthermore, beryllium oxides packages shall not be placed in acids that will produce fumes containing beryllium.

International
IR Rectifier

WORLD HEADQUARTERS: 233 Kansas St., El Segundo, California 90245, Tel: (310) 322 3331

EUROPEAN HEADQUARTERS: Hurst Green, Oxted, Surrey RH8 9BB, UK Tel: ++ 44 1883 732020

IR CANADA: 7321 Victoria Park Ave., Suite 201, Markham, Ontario L3R 2Z8, Tel: (905) 475 1897

IR GERMANY: Saalburgstrasse 157, 61350 Bad Homburg Tel: ++ 49 6172 96590

IR ITALY: Via Liguria 49, 10071 Borgaro, Torino Tel: ++ 39 11 451 0111

IR FAR EAST: K&H Bldg., 2F, 3-30-4 Nishi-Ikeburo 3-Chome, Toshima-Ki, Tokyo Japan 171 Tel: 81 3 3983 0086

IR SOUTHEAST ASIA: 315 Outram Road, #10-02 Tan Boon Liat Building, Singapore 0316 Tel: 65 221 8371

<http://www.irf.com/>

Data and specifications subject to change without notice.

6/96